

A Note on “Capability Assessment for Processes with Multiple Characteristics: A Generalization of the Popular Index C_{pk} ”

W. L. Pearn, C. H. Wu^{*,†} and M. C. Tsai

The generalized yield index C_{pk}^T establishes the relationship between the manufacturing specifications and the actual process performance, which provides a lower bound on process yield for two-sided processes with multiple characteristics. The results attended are very practical for industrial application. In this article, we extended the results in cases with one-sided specification and multiple characteristics. The generalized index C_{PU}^T was considered, and the asymptotic distribution of the natural estimator \hat{C}_{PU}^T was developed. Then, we derived the lower confidence bounds as well as the critical values of index C_{PU}^T . We not only provided some tables but also presented an application example. Copyright © 2012 John Wiley & Sons, Ltd.

Keywords: critical values; lower confidence bounds; multiple characteristics; one-sided specification; process capability index

1. Introduction

Process yield has been the most basic and common criterion used in the manufacturing industry as a base for measuring process performance. Recently, Pan and Lee² developed two novel indices to evaluate the performance of multivariate manufacturing process. The effects of the estimation of process capability index (PCI) on the nonconforming units in parts per million (NCPMP) estimates are analyzed by Ozkaya and Testik.³ Later, Lin and Pearn⁴ used the yield index S_{pk} to deal with process selection problem. Itay *et al.*⁵ investigated an advanced multistage sampling plan based on C_{pk} index.

Afterward, Yum and Kim⁶ provided a bibliography of PCIs for 2000–2009. Spiring⁷ then presented several method of process capability using Mathematica 7 software. Next, an applicable methodology to achieve the robustness of the multivariate process capability vector was proposed by Awad and Kovach.⁸ Lately, more dissertations about PCI were published such as Pearn *et al.*,⁹ Hsu *et al.*,¹⁰ Yen and Pearn,¹¹ Pearn and Cheng,¹² and Goethals and Cho.¹³ It can be observed that the new investigations of PCI mainly focus on processes with multivariate or multiple characteristics.

Pearn *et al.*¹⁴ proposed a generalization of the popular index C_{pk} for evaluating the yield of a gold bumping manufacturing process with multiple characteristics. The C_{pk}^T index is defined for a process with multiple characteristics and two-sided specifications. However, the quality characteristics often have only one-sided specification. At this time, the overall capability index C_{PU}^T proposed by Wu and Pearn¹ is considered for this purpose. The index C_{PU}^T is defined as follows:

$$C_{PU}^T = \frac{1}{3} \Phi^{-1} \left\{ \prod_{i=1}^m \Phi(3C_{PUi}) \right\} \quad (1)$$

where C_{PUi} denotes the C_{PU} value of the i th characteristic for $i=1, 2, \dots, m$, and m is the number of characteristics. $\Phi(\cdot)$ is the cumulative distribution function of standard normal distribution. A one-to-one correspondence relationship between C_{PU}^T and the overall process NCPMP can be demonstrated as

$$NCPMP = 10^6 \times [1 - \Phi(3C_{PU}^T)] \quad (2)$$

Department of Industrial Engineering and Management, National Chiao Tung University, Taiwan, ROC

*Correspondence to: C. H. Wu, Department of Industrial Engineering and Management, National Chiao Tung University, 1001 University Road, Hsinchu, Taiwan 300, ROC.

†E-mail: hexjaca.liem96g@nctu.edu.tw

2. Approximation distribution of the natural estimator

Consider the natural estimator of C_{PU}^T as

$$\hat{C}_{PU}^T = \frac{1}{3} \Phi^{-1} \left\{ \prod_{i=1}^m \Phi(3\hat{C}_{PUi}) \right\} = \frac{1}{3} \Phi^{-1} \left\{ \prod_{i=1}^m \Phi \left(\frac{USL - \bar{X}_i}{S_i} \right) \right\}, i = 1, \dots, m \quad (3)$$

where \bar{X}_i and S_i denote the sample mean and sample variance of i th characteristic. The exact distribution of \hat{C}_{PU}^T is mathematically intractable. By taking the first order of the Taylor expansion (see Appendix), the asymptotic distribution of \hat{C}_{PU}^T is

$$\hat{C}_{PU}^T \approx N \left(C_{PU}^T, \frac{1}{9n [\phi(3C_{PU}^T)]^2} \sum_{i=1}^m (a_i^2 + b_i^2) \right) \quad (4)$$

where

$$a_i = \left[\prod_{j=1, j \neq i}^m \Phi(3C_{PUj}) \right] \phi(3C_{PUi}) \text{ and } b_i = \frac{3C_{PUi}}{\sqrt{2}} a_i, i = 1, \dots, m$$

3. Estimation and testing on C_{PU}^T

From Equation (4), it can be seen that \hat{C}_{PU}^T is an asymptotic unbiased estimator of C_{PU}^T . The determination of the lower confidence bound on the actual process capability is essential for quality assurance. An approximate $100(1 - \alpha)\%$ lower confidence bound for C_{PU}^T can be expressed as

$$C_{PU}^{T, LB} \approx \hat{C}_{PU}^T - z_\alpha \left[\frac{1}{9n [\phi(3\hat{C}_{PU}^T)]^2} \sum_{i=1}^m (a_i^2 + b_i^2) \right]^{1/2} \quad (5)$$

It is noted that a_i and b_i parameters are unknown in Equation (5). To investigate the effects of C_{PU_i} on $C_{PU}^{T, LB}$, the cases with processes that have two independent characteristics are considered. Figure 1 displays the curves of $C_{PU}^{T, LB}$ for various combinations of C_{PU_1} and C_{PU_2} , with $C_{PU}^T = 1.0, 1.33, 1.5, 1.67$. Then, we examined the results presented in Figure 1, which indicate that

- (i) $C_{PU}^{T, LB}$ obtains its absolute maximum as $C_{PU_1} = C_{PU_2}$.
- (ii) The minimum $C_{PU}^{T, LB}$ occurs when one of C_{PU_i} approaches infinity, that is, another C_{PU_i} equals C_{PU}^T . Under this condition, the minimum $C_{PU}^{T, LB}$ is the most reliable lower confidence bound for a given C_{PU}^T .

By the discussion mentioned earlier, after doing some algebra, the asymptotic distribution of \hat{C}_{PU}^T becomes

$$\hat{C}_{PU}^T \approx N \left(C_{PU}^T, \frac{1}{9n} + \frac{1}{2n} C_{PU}^{T, 2} \right) \quad (6)$$

Therefore, an approximate $100(1 - \alpha)\%$ lower confidence bound for C_{PU}^T can be expressed as

$$C_{PU}^{T, LB} = \frac{2\hat{C}_{PU}^T - \sqrt{\frac{4z_\alpha^2}{9n} + \frac{2z_\alpha^2}{n} \hat{C}_{PU}^{T, 2} - \frac{2z_\alpha^4}{9n^2}}}{2 - z_\alpha^2/n} \quad (7)$$

Table I tabulates the 95% lower confidence bound $C_{PU}^{T, LB}$ for $\hat{C}_{PU}^T = 1.0(0.1)2.0, n = 10(10)400$. For the convenience of hypothesis testing, we also provide the critical value. From the asymptotic distribution listed in Equation (6), the critical value to hypothesis testing $H_0 : C_{PU}^T \leq C$ versus $H_a : C_{PU}^T > C$ is expressed as

$$c_0 = C + z_\alpha \sqrt{\frac{1}{9n} + \frac{C^2}{2n}} \quad (8)$$

Table II performs the critical values for type I error $\alpha = 0.05$ with $C = 1.0(0.1)2.0, n = 10(10)400$. Next, an application example is presented.

4. A case study

We applied the methodology to a set of real data ($n = 100$) presented in Wu and Pearn¹ for measuring manufacturing capability of a process making couplers and wavelength division multiplexers (WDM). Two quality characteristic including the polarization-dependent

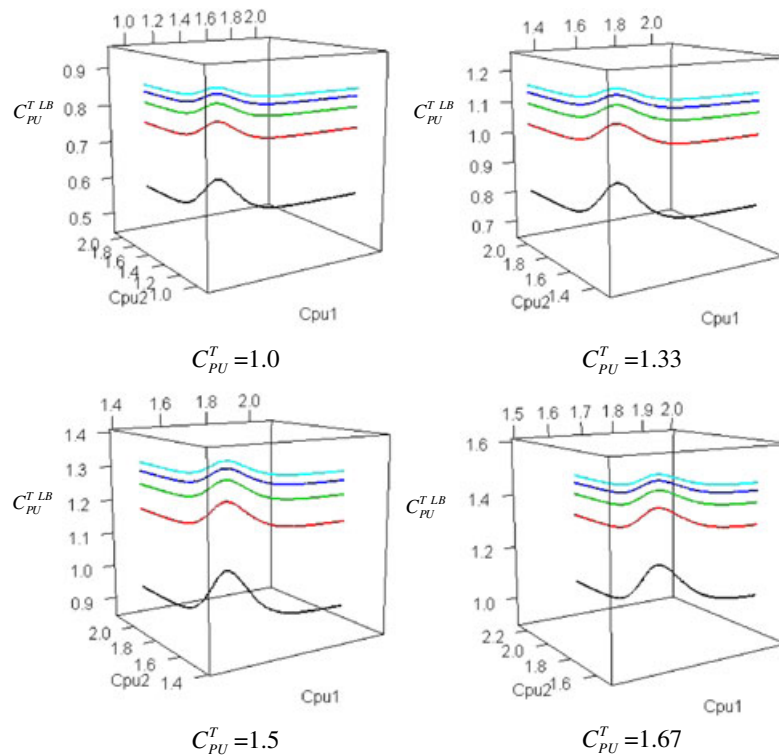


Figure 1. Curves of $C_{PU}^{T, LB}$ with $\alpha=0.05$, $n=10(20)90$ (bottom to top in plot) and $C_{PU}^T=1.0, 1.33, 1.5, 1.67$

Table I. 95% lower confidence bounds of C_{PU}^T for $\hat{C}_{PU}^T=1.0(0.1)2.0$, $n=10(10)400$

n	\hat{C}_{PU}^T										
	1.0	1.1	1.2	1.3	1.4	1.5	1.6	1.7	1.8	1.9	2.0
10	0.6920	0.7684	0.8443	0.9198	0.9950	1.0700	1.1447	1.2192	1.2936	1.3679	1.4420
20	0.7661	0.8477	0.9291	1.0101	1.0909	1.1716	1.2521	1.3324	1.4127	1.4929	1.5729
30	0.8024	0.8867	0.9708	1.0547	1.1384	1.2219	1.3053	1.3886	1.4718	1.5550	1.6380
40	0.8252	0.9113	0.9972	1.0828	1.1683	1.2537	1.3390	1.4241	1.5092	1.5943	1.6792
50	0.8414	0.9287	1.0158	1.1027	1.1895	1.2762	1.3628	1.4493	1.5358	1.6221	1.7085
60	0.8536	0.9419	1.0299	1.1178	1.2056	1.2933	1.3809	1.4684	1.5559	1.6433	1.7307
70	0.8633	0.9523	1.0411	1.1298	1.2184	1.3069	1.3953	1.4836	1.5719	1.6601	1.7483
80	0.8712	0.9608	1.0503	1.1396	1.2288	1.3180	1.4070	1.4960	1.5850	1.6739	1.7627
90	0.8778	0.9680	1.0580	1.1479	1.2376	1.3273	1.4169	1.5065	1.5960	1.6854	1.7749
100	0.8835	0.9741	1.0646	1.1549	1.2451	1.3353	1.4254	1.5154	1.6054	1.6953	1.7852
120	0.8928	0.9841	1.0753	1.1664	1.2574	1.3483	1.4392	1.5300	1.6208	1.7115	1.8022
150	0.9032	0.9954	1.0874	1.1794	1.2712	1.3630	1.4548	1.5465	1.6381	1.7297	1.8213
180	0.9111	1.0039	1.0965	1.1891	1.2816	1.3741	1.4665	1.5588	1.6511	1.7434	1.8357
200	0.9153	1.0084	1.1015	1.1944	1.2873	1.3801	1.4728	1.5655	1.6582	1.7509	1.8435
250	0.9237	1.0175	1.1112	1.2048	1.2984	1.3919	1.4854	1.5788	1.6722	1.7656	1.8589
300	0.9300	1.0243	1.1185	1.2126	1.3067	1.4008	1.4948	1.5887	1.6827	1.7766	1.8705
350	0.9349	1.0296	1.1242	1.2188	1.3133	1.4077	1.5021	1.5965	1.6909	1.7852	1.8795
400	0.9389	1.0339	1.1289	1.2237	1.3186	1.4134	1.5081	1.6028	1.6975	1.7922	1.8869

loss and the insertion loss, which are critical in fiber-optic transmission quality, are considered. Table III (cited from Wu and Pearn¹) displays the manufacturing capabilities and the corresponding NCPPM for coupler and WDM process using \hat{C}_{PU}^T values and $C_{PU}^{T, LB}$.

In the coupler case, if the quality requirement is $C_{PU}^T \geq 1.3$, some statistical inferences can be made. First, because the 95% lower confidence bound $C_{PU}^{T, LB} = 1.35588 > 1.3$, we say that the process satisfies the requirement. Moreover, $C_{PU}^{T, LB} = 1.35588$ means that there are no more than 23.7 NCPPM, or, from Table III, the critical value 1.460835 ($n = 100$, $C = 1.3$) is less than the observation value $\hat{C}_{PU}^T = 1.5261$. The two results are agreed. In WDM case, $\hat{C}_{PU}^T = 0.7352 < 1$ is obviously inadequate and incapable for high-tech product manufacturing.

Table II. Critical values c_0 for $C = 1.0(0.1)2.0$, $n = 10(10)400$

n	C										
	1.0	1.1	1.2	1.3	1.4	1.5	1.6	1.7	1.8	1.9	2.0
10	1.4066	1.5401	1.6741	1.8086	1.9433	2.0783	2.2134	2.3488	2.4843	2.6200	2.7557
20	1.2875	1.4112	1.5353	1.6596	1.7841	1.9089	2.0338	2.1588	2.2839	2.4091	2.5344
30	1.2347	1.3541	1.4737	1.5936	1.7136	1.8338	1.9541	2.0746	2.1951	2.3156	2.4363
40	1.2033	1.3200	1.4370	1.5543	1.6716	1.7891	1.9067	2.0244	2.1421	2.2600	2.3778
50	1.1818	1.2968	1.4120	1.5274	1.6429	1.7586	1.8743	1.9901	2.1060	2.2219	2.3379
60	1.1660	1.2796	1.3935	1.5076	1.6218	1.7360	1.8504	1.9648	2.0793	2.1939	2.3085
70	1.1536	1.2663	1.3792	1.4922	1.6053	1.7185	1.8318	1.9452	2.0586	2.1721	2.2856
80	1.1437	1.2556	1.3676	1.4798	1.5920	1.7044	1.8169	1.9294	2.0419	2.1545	2.2672
90	1.1355	1.2467	1.3580	1.4695	1.5811	1.6927	1.8044	1.9162	2.0281	2.1400	2.2519
100	1.1285	1.2391	1.3499	1.4608	1.5718	1.6828	1.7940	1.9051	2.0164	2.1276	2.2389
120	1.1173	1.2270	1.3368	1.4468	1.5568	1.6669	1.7771	1.8873	1.9975	2.1078	2.2181
150	1.1049	1.2136	1.3224	1.4313	1.5402	1.6493	1.7584	1.8675	1.9767	2.0859	2.1951
180	1.0958	1.2037	1.3117	1.4198	1.5280	1.6363	1.7446	1.8529	1.9613	2.0697	2.1781
200	1.0909	1.1984	1.3060	1.4137	1.5214	1.6293	1.7371	1.8450	1.9530	2.0609	2.1689
250	1.0813	1.1880	1.2948	1.4017	1.5086	1.6156	1.7226	1.8297	1.9368	2.0440	2.1511
300	1.0742	1.1803	1.2865	1.3928	1.4991	1.6055	1.7120	1.8184	1.9249	2.0314	2.1379
350	1.0687	1.1744	1.2801	1.3859	1.4918	1.5977	1.7036	1.8096	1.9156	2.0217	2.1277

Table III. Calculations for process capability of the coupler and WDMs

Characteristic	\hat{C}_{PU}^T	NCPMP	$\hat{C}_{PU}^{T, LB}$	NCPMP
Coupler	1.5261	2.3439	1.3588	22.86916
WDM	0.7352	13706.01	0.6425	26958.67

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Authors' biographies

Wen-Lea Pearn received the Ph.D. degree in operations research from the University of Maryland, College Park. He is a Professor of Operations Research and Quality Assurance at the National Chiao-Tung University (NCTU), Hsinchu, Taiwan. He was with Bell Laboratories, Murray Hill, NJ, as a Quality Research Scientist before joining the NCTU, and others. His current research interests include process capability, network optimization, and production management. Dr. Pearn's publications have appeared in the Journal of the Royal Statistical Society, Series C, Journal of Quality Technology, European Journal of Operational Research, Journal of the Operational Research Society, Operations Research Letters, Omega, Networks, and the International Journal Productions Research.

Chia-Huang Wu received his MS degree in Applied Mathematics from National Chung-Hsing University. Currently, he is a PhD candidate at the Department of Industrial Engineering and Management, National Chiao Tung University, Taiwan, ROC.

Meng-Chun Tsai received her MS degree in Department of Industrial Engineering and Management, National Chiao Tung University, Taiwan, ROC.